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Characterization of SnO<sub>x</sub>-Coated Lithium Manganese Oxide Thin Film Hee-Soo Moon<sup>a</sup>, Jae-Ho Lee<sup>a</sup>, Young-Jae Kim<sup>a</sup> and Jong-Wan Park<sup>a,b,\*</sup>

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Lithium manganese oxide (LiMn2O4) is promising material for Li-ion rechargeable batteries and thin film batteries (TFBs). However, poor properties, such as instability in elevated temperature and lower practical capacity, interfere with commercialization. To improve the electrochemical properties of LiMn<sub>2</sub>O<sub>4</sub>, transitionmetal substitution method has been performed [1]. However, this method induced discharge capacity reduction, because of diminution of  $\mathrm{Mn}^{3+}$  ions, which was reacted with Li<sup>+</sup> ions when intercalation process. To improve the properties without capacity reduction, anion doping method [2] and surface treatment, such as oxide coating [3], was introduced. In our previous study, we introduced protective layer for cathode thin film by ECR-CVD [4]. In our work, we introduced SnO<sub>x</sub> thin film as protective layer for cathode thin film.

Lithium manganese oxide cathode was deposited by rf magnetron sputter on Pt deposited  $TiO_2/SiO_2/Si(100)$  wafer. In order to make spinal phase, post-annealing process introduced. The annealed film thickness was about 200 nm.  $SnO_x$  film was deposited by using same sputtering system with stoichiometric  $SnO_2$  target. The  $SnO_x$  film thickness on the spinel film was controlled by the deposition time.

Surface roughness and morphologies of the film was measured by AFM and FE-SEM. The chemical bonding was analyzed by XPS. The elements on the surface were measured by AES depth profile method. For electrochemical analysis, half-cells were made with the deposited film as cathode, the lithium metal as anode, and 1 M solution of LiPF<sub>6</sub> in EC-DMC(1:1) as electrolyte.

As shown in Fig. 1,  $LiMn_2O_4$  was covered totally covered by  $SnO_x$  film. Fig. 2 and Fig. 3 showed that cycleability in high C-rate and in the elevated temperature was improved by the  $SnO_x$ -protective layer due to avoid direct contact between  $LiMn_2O_4$  and liquid electrolyte.

The more results will be presented in the meeting.

## ACKNOWLEDGEMENT

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Figure 1. XPS surveys of the non-coated  $LiMn_2O_4$  and the  $SnO_x - 1$  min coated  $LiMn_2O_4$ .



Figure 2. Discharge capacities of the non-coated  $LiMn_2O_4$ and the  $SnO_x - 1$  min coated  $LiMn_2O_4$ .



Figure 3. Discharge capacities of the non-coated  $LiMn_2O_4$ and the  $SnO_x$ -coated  $LiMn_2O_4$  in the elevated temperature.